



BRAINWARE UNIVERSITY

Term End Examination 2024-2025
Programme – B.Tech.(RA)-2022
Course Name – Nano Electronics
Course Code - PEC-ECR601B
(Semester VI)

Full Marks: 60 Time: 2:30 Hours

[The figure in the margin indicates full marks. Candidates are required to give their answers in their own words as far as practicable.]

Group-A

(Multiple Choice Type Question)

1 x 15=15

- Choose the correct alternative from the following :
- (i) Identify the element with one dimension in Nano range and the other two dimensions in large range
 - a) Micro-material

b) Quantum wire

c) Quantum well

- d) Quantum dot
- (ii) Select the condition of the melting point of particles in nano form
 - a) Increases

b) Decreases

c) Remains same

- d) Increases then decreases
- (iii) Identify the processes of materials was not described as Nanotechnology
 - a) Separation

b) Creation

c) Processing

- d) Consolidation
- (iv) Express the main issue obtained in system integration related to interconnects
 - a) Decreasing interconnect resistance
- b) Increasing interconnect capacitance
- c) Decreasing interconnect length
- d) Increasing interconnect delay
- (v) Identify that the short channel effect is resulting from
 - a) small drain depletion region
- b) change in electron drift characteristics
- c) depletion charge sharing between the gate , the source and the drain
- d) None of these
- (vi) Indicate which one does not minimize punch-through
 - a) long channel

b) weaker substrate doping

c) thinner oxide

- d) shallower junction
- (vii) Identify that short channel effect can be characterized by
 - a) saturation drain current depends quadratically upon overdrive voltage
- b) bulk depletion region becomes assymetrical in shape instead of a rectangular structure
- c) drain depletion region becomes larger than source depletion region
- d) threshold voltage decreases with effective channel length
- (viii) Identify how many carbon atom present in C80 Fullerene

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a) 40 c) 120	one have faster switching	d) 80 speed	
(ix) Identify which	AOCEET	b) FinFET	
a) Double gate	ante MOSFET	d) none of these	
c) Surrounding (x) For the synthes	is of CNTs, choose the ma	ximum temperature for which the	quartz tube
is heated up		b) 1200°C	
a) 1000°C		d) 1600°C	
c) 1400°C	rect application of CNT fro	m the following	
		b) High voltage batteries	
a) Paper batterie	3S	d) Clock batteries	
c) Car batteries	non nanostructure with w	hich CNTs are capped on both end	ls
	JOH Harlosti actar c arrange	b) Diamond	
a) Graphite		d) Benzene	
c) C60	ificant advantage of Single		
		h) Law power consumption	•
a) High-speed or	peration	b) Low power consumption	
c) Large size	1:55 - 5:::::	d) High fabrication complex	xity
The state of the s	SET differ from a conventi		
	ner power consumption	b) SETs operate at room ter	
c) SETs control si	ngle electrons	d) SETs have lower fabricat	
(xv) For the operatio voltage	n of enhancement only N	-channel MOSFET , identify the na	ture of gate
a) Positive		b) Negative	
c) Zero		d) none of these	
	and the second of the second	Group-B	
	(Short Ansv	ver Type Questions)	3 x 5=15
2. State and explain M	loore's Law.		(3)
7.0			, `-'
3. Discuss the advanta	ge of double gate MOSFE	Т.	(3)
4 Fundain de constant	P 12 15 15 15 15 15 15 15 15 15 15 15 15 15		
4. Explain the various	applications of quantum o	lots.	(3)
5. Describe Eigen value	and Figen function		(2)
D. Describe Eigen Value	. and Ligen function.		(3)
6. Distinguish diamond	and graphite.		(3)
			(5)
		OR	
Distinguish single wa	ll nanotube and multiwal	I nanotube.	(3)
			(3)
	G	iroup-C	
		er Type Questions)	5 x 6=30
			J X 0-30
Explain why gate-en	gineering techniques are	used for reduction of SCEs.	
	o sominques are	used for reduction of SCFs	(5)

8. Explain the potential applications of resonant tunnelling diode.

- (5)
- 9. Justify the density of state is dependent on the dimension of a material by the following relation
- (5)

$$D(E) \propto E^{\frac{d}{2}-1}$$

Where d is thee dimensionality of the system.

10. Describe Short Channel Effects.

- (5)
- 11. Describe the nanoscale MOSFET and its advantages in semiconductor technology.
- (5)

12. Compare different types of hybridization observed in carbon.

(5)

OR

Compare Single Electron Transistor and Conventional Transistor.

(5)